

## EAST Search History

| Ref # | Hits | Search Query  | DBs   | Default Operator | Plurals | Time Stamp          |
|-------|------|---|---|------------------|---------|---------------------|
| L1    | 214  | (SiOC or SiON or ARC or TERA)with<br>(Oxygen near plasma)   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | OFF     | 2008/06/04<br>21:43 |
| L2    | 58   | ((SiOC or SiON or ARC or TERA)with<br>(Oxygen near plasma))and (flow\$4 near<br>rate)                       | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | OFF     | 2008/06/04<br>21:44 |
| L3    | 43   | ((SiOC or SiON or ARC or TERA)with<br>(Oxygen near plasma))and (oxygen with<br>(scm or(flow\$4 near rate))) | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | ON      | 2008/06/04<br>21:45 |
| S1    | 0    | 10/702049   | USPAT   | OR               | OFF     | 2007/09/17<br>16:19 |
| S2    | 2    | 10/702049   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | OFF     | 2007/09/18<br>12:50 |
| S4    | 72   | "6316167"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | OFF     | 2007/09/18<br>17:08 |
| S5    | 7252 | ((430/313/) or (430/272.1/) or (430/311/)<br>or (427/569/) or (427/282/) or (427/535/)).<br>CCLS.           | USPAT; USOCR  | OR               | OFF     | 2007/09/18<br>17:09 |
| S7    | 3    | S5 and TERA   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | OFF     | 2007/09/18<br>17:11 |
| S8    | 1666 | S5 and deposit  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | OFF     | 2007/09/18<br>17:11 |
| S9    | 0    | S5 and deposit and etch and R:C:H:X   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | OFF     | 2007/09/18<br>17:12 |

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| S10 | 0  | S5 and deposit and R:C:H:X | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>17:12 |
| S11 | 0  | S5 and deposit and R:C:O:X | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>17:12 |
| S12 | 2  | S5 and R:C:O:X             | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>17:13 |
| S13 | 2  | S5 and RCHX                | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>17:14 |
| S14 | 37 | RCHX                       | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>17:14 |
| S15 | 5  | RCHX and deposit           | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>17:14 |
| S16 | 0  | RCHX and deposit and HZ    | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>19:09 |
| S17 | 5  | RCHX and deposit           | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>17:16 |
| S18 | 2  | "20040178169"              | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/21<br>21:18 |
| S19 | 0  | RCHX and HZ and watt       | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>19:09 |

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| S20 | 2      | RCHX and HZ   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>19:10 |
| S21 | 4      | "6903023"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>19:12 |
| S22 | 2      | "20070037100"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>19:15 |
| S23 | 2      | "20060049139"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>19:16 |
| S24 | 2      | "20040000534"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>19:26 |
| S25 | 4      | "1905170"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>19:27 |
| S26 | 0      | "19901905170"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>19:27 |
| S27 | 121    | "4905170"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/18<br>19:28 |
| S28 | 82     | "4905170"   | USPAT; USOCR  | OR | OFF | 2007/09/19<br>12:31 |
| S29 | 1      | 2002/0076843  | USPAT; USOCR  | OR | OFF | 2007/09/19<br>12:32 |
| S30 | 1      | 2002/0076843  | USPAT; USOCR  | OR | OFF | 2007/09/19<br>12:33 |
| S31 | 6      | "6287959"   | USPAT; USOCR  | OR | OFF | 2007/09/19<br>12:36 |
| S32 | 20     | "6380611"   | USPAT; USOCR  | OR | OFF | 2007/09/19<br>12:41 |
| S33 | 439343 | (ARC or (anti near reflect\$3 near coat\$4))<br>deposit and rate and time | USPAT; USOCR  | OR | OFF | 2007/09/19<br>12:43 |

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|-----|-------|---|--|----|-----|------------------|
| S34 | 110   | (ARC or (anti near reflect\$3 near coat\$4)) with deposit with rate   | USPAT; USOCR   | OR | OFF | 2007/09/19 12:44 |
| S35 | 1     | (anti near reflect\$3 near coat\$4) with deposit with rate  | USPAT; USOCR   | OR | OFF | 2007/09/19 12:47 |
| S36 | 8249  | tetramethylcyclotetrasilicate or tetraethylorthosilicate or dimethyldimetoxy silane or octamethylcyclotetrasiloxane | USPAT; USOCR   | OR | OFF | 2007/09/19 12:50 |
| S37 | 13879 | tetramethylcyclotetrasilicate or tetraethylorthosilicate or dimethyldimetoxy silane or octamethylcyclotetrasiloxane | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/09/19 13:20 |
| S38 | 1405  | S37 and deposit and etch  | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/09/19 12:52 |
| S39 | 0     | "I0" and ( deposit near ratea)  | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/09/19 12:52 |
| S40 | 0     | "I0" and ( deposit near rate)   | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/09/19 12:52 |
| S41 | 0     | "I0" and ( deposit near rate)   | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/09/19 12:52 |
| S42 | 1     | "I10" and ( deposit near rate)  | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/09/19 12:53 |
| S43 | 95    | "I10" and ((inert near gas) or nitrogen or argon)   | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/09/19 12:54 |
| S44 | 2     | "10662022"  | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/09/19 13:11 |

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| S45 | 4   | "7030468"                            | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/19<br>13:21 |
| S46 | 2   | "10377061"                           | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/19<br>17:09 |
| S47 | 1   | 11/023815                            | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/19<br>17:10 |
| S48 | 1   | 11/023815                            | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/19<br>17:10 |
| S49 | 4   | "7097779"                            | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/21<br>21:26 |
| S50 | 0   | "SiOH" with etch with "DC" with bias | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/21<br>21:27 |
| S51 | 1   | "RCHX" with etch with "DC" with bias | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/24<br>17:44 |
| S52 | 1   | 11/801058                            | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/09/24<br>17:45 |
| S53 | 50  | "6316167"                            | USPAT   | OR | OFF | 2007/10/03<br>15:21 |
| S54 | 50  | "6316167"                            | USPAT   | OR | OFF | 2007/10/03<br>15:23 |
| S55 | 53  | etch and SiCH and hydrogen           | USPAT   | OR | OFF | 2007/10/03<br>15:23 |
| S56 | 166 | etch and SiCH and hydrogen           | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/03<br>15:23 |

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| S57 | 202 | etch with SiCH with hydrogen                               | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/03<br>15:23 |
| S58 | 0   | etch with SiCH with hydrogen                               | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/03<br>15:23 |
| S59 | 6   | etch same SiCH same hydrogen                               | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/03<br>15:25 |
| S60 | 0   | etch same SiCH same hydrogen and sccm                      | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/03<br>15:25 |
| S61 | 6   | etch same SiCH same hydrogen and rate                      | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/03<br>15:27 |
| S62 | 6   | "7183201"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/03<br>15:30 |
| S63 | 4   | 09/912103  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/03<br>15:30 |
| S64 | 1   | "7030008"  | USPAT   | OR | OFF | 2007/10/04<br>10:24 |
| S65 | 0   | "20050100683"  | USPAT   | OR | OFF | 2007/10/04<br>10:25 |
| S66 | 1   | "20050100683"  | US-PGPUB;<br>USPAT  | OR | OFF | 2007/10/04<br>11:09 |
| S67 | 45  | "6063233"  | US-PGPUB;<br>USPAT  | OR | OFF | 2007/10/04<br>11:34 |
| S68 | 17  | plasma and deposition and SiCOH and shower and temperature | US-PGPUB;<br>USPAT  | OR | OFF | 2007/10/04<br>11:35 |
| S69 | 17  | plasma and deposition and SiCOH and shower and temperature | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>11:35 |

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| S70 | 18 | plasma and deposit\$4 and SiCOH and shower and temperature  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>11:36 |
| S71 | 6  | plasma and deposit\$4 and SiCOH and (shower with temperature)   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>11:46 |
| S72 | 0  | (plasma with deposit\$4 with SiCOH)and (post near process)and (( de near chuck) or remove or lift)                                | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>11:47 |
| S73 | 0  | (plasma same deposit\$4 same SiCOH)and (post near process)and (( de near chuck) or remove or lift)                                | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>11:48 |
| S74 | 4  | (plasma and deposit\$4 and SiCOH)and (post near process)and (( de near chuck) or remove or lift)                                  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>12:16 |
| S75 | 15 | plasma and deposit\$4 and (TERA or SiCOH or organosilicate)and(post near process)and (( de near chuck) or remove or lift)         | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>12:26 |
| S76 | 15 | plasma and deposit\$4 and (TERA or SiCOH or SiCNH or organosilicate)and(post near process)and(( de near chuck) or remove or lift) | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>12:30 |
| S77 | 7  | 2002-194431   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>12:35 |
| S78 | 24 | "6380611"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>12:36 |
| S79 | 7  | "6287959"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>12:39 |

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| S80 | 2  | "20020076843"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>12:45 |
| S81 | 57 | SiCOH and deposit and plasma and<br>(tetramethylcyclotetrasilane or<br>tetraethylorthosilicate or<br>dimethyldimethoxysilane or<br>octamethylcyclotetrasiloxane)       | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>12:47 |
| S82 | 24 | SiCOHwith deposit with plasma with<br>(tetramethylcyclotetrasilane or<br>tetraethylorthosilicate or<br>dimethyldimethoxysilane or<br>octamethylcyclotetrasiloxane)     | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>13:06 |
| S83 | 0  | SiCOH with deposit with plasma with<br>(tetramethylcyclotetrasilane or<br>tetraethylorthosilicate or<br>dimethyldimethoxysilane or<br>octamethylcyclotetrasiloxane)    | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>13:06 |
| S84 | 0  | SiCOH same deposit same plasma same<br>(tetramethylcyclotetrasilane or<br>tetraethylorthosilicate or<br>dimethyldimethoxysilane or<br>octamethylcyclotetrasiloxane)    | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>13:06 |
| S85 | 0  | SiCOH same deposit same plasma same<br>(tetramethylcyclotetrasilane or<br>tetraethylorthosilicate or<br>dimethyldimethoxysilane or<br>octamethylcyclotetrasiloxane)    | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>13:06 |
| S86 | 57 | SiCOH and deposit and plasma and<br>(tetramethylcyclotetrasilane or<br>tetraethylorthosilicate or<br>dimethyldimethoxysilane or<br>octamethylcyclotetrasiloxane)       | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>13:07 |
| S87 | 75 | (SiCOH with deposit\$4) and plasma and<br>(tetramethylcyclotetrasilane or<br>tetraethylorthosilicate or<br>dimethyldimethoxysilane or<br>octamethylcyclotetrasiloxane) | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/04<br>13:22 |
| S88 | 72 | "6316167"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>02:47 |
| S89 | 3  | "20030017694"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>03:08 |



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| S90 | 72       | "6316167"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>03:40 |
| S91 | 33       | "6436808"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>03:40 |
| S92 | 2        | deposit and chamber and (SiOH)and<br>(shower with temperature) | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>03:46 |
| S93 | 19466105 | US "6764951" B1  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>03:44 |
| S94 | 4        | "6764951"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>03:45 |
| S95 | 6        | (SiOH)and (shower with temperature)                            | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>05:36 |
| S96 | 5        | (SiOH)and (shower with temperature)                            | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>03:51 |
| S97 | 6        | organosilicon and (shower with<br>temperature)                 | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>03:52 |
| S98 | 19       | "885985"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>04:26 |
| S99 | 2        | "20030003768"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>04:26 |

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| S100 | 2   | ("SiCOH" or organosilicate)and (shower with temperature)and deposit                 | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>05:37 |
| S101 | 2   | ("SiCOH" or organosilicate)and (shower with temperature)and deposit                 | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:17 |
| S102 | 16  | "638803"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>05:40 |
| S103 | 21  | ("SiCOH" or organosilicate)and (wall with temperature)and deposit                   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>05:53 |
| S104 | 9   | "938435"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>05:53 |
| S105 | 2   | ("SiCOH" or organosilicate)and (shower with (temperature or centigrade))and deposit | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:24 |
| S106 | 16  | "638803"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:22 |
| S107 | 331 | (shower with (temperature or centigrade)) and deposit                               | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:24 |
| S108 | 180 | (shower with (temperature or centigrade)) and deposit and uniform                   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:24 |
| S109 | 3   | (shower with (temperature or centigrade)) with deposit with uniform                 | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:28 |

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|------|----|---|---|----|-----|---------------------|
| S110 | 21 | (shower with (temperature or centigrade))<br>with deposit               | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:43 |
| S111 | 0  | (( de near chuck\$3) with substrate or<br>wafer)with while with plasma  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:47 |
| S112 | 0  | (( de near chuck\$3) with substrate or<br>wafer)with while with deposit | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:47 |
| S113 | 0  | (( de near chuck\$3) with substrate or<br>wafer)same while same deposit | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:47 |
| S114 | 0  | (( de near chuck\$3) same substrate or<br>wafer)same while same deposit | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:47 |
| S115 | 0  | ( de near chuck\$3) and (substrate or wafer)<br>and while and deposit   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:48 |
| S116 | 0  | (( de near chuck\$3)with (substrate or<br>wafer)))and while and deposit | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>06:53 |
| S117 | 77 | (( de near chuck\$3)with (substrate or<br>wafer))) and deposit          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>07:00 |
| S118 | 1  | (( de adj chuck\$3)with (substrate or<br>wafer))) with deposit          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>07:00 |
| S119 | 1  | (( de adj chuck\$3)with (substrate or<br>wafer))) same deposit          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>07:00 |

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|------|------|--|---|----|-----|---------------------|
| S120 | 1    | (( ( de adj chuck\$3) same (substrate or wafer))) same deposit   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>07:00 |
| S121 | 77   | (( ( de adj chuck\$3) same (substrate or wafer))) and deposit  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>07:01 |
| S122 | 76   | (( ( de adj chuck\$3) same (substrate or wafer))) and deposit and (during or while or after or before) | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>07:12 |
| S123 | 5440 | (( ( lift\$3) with (substrate or wafer))) and deposit and (during or while or after or before)         | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>07:12 |
| S124 | 71   | (( ( lift\$3) with (substrate or wafer))) with deposit with (during or while or after or before)       | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>07:13 |
| S125 | 71   | (( ( lift\$3) with (substrate or wafer))) with deposit with (during or while or after or before)       | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/13<br>07:13 |
| S126 | 2    | "5466524"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/15<br>18:42 |
| S127 | 1    | "10546736"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/15<br>18:43 |
| S128 | 1    | "10546736"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/15<br>18:44 |
| S129 | 1    | 10/534401  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/15<br>18:44 |

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|------|----|---|---|----|-----|---------------------|
| S130 | 64 | plasma and ( de near chuck)   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/24<br>19:17 |
| S131 | 6  | "6452775"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>11:25 |
| S132 | 0  | (de near chuk) and ( plasma near deposit \$4)                           | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>11:25 |
| S133 | 1  | (de near chuck) and ( plasma near deposit \$4)                          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>11:28 |
| S134 | 39 | (de near chuck) and ( plasma with deposit \$4)                          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>11:28 |
| S135 | 2  | "20050100683"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>11:57 |
| S136 | 2  | "20050100683"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>11:58 |
| S137 | 1  | ((de near chuck or " de-chuck") with (plasma near(coat\$4 or deposit))) | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>12:00 |
| S138 | 1  | ((de near chuck or " de-chuck") same (plasma near(coat\$4 or deposit))) | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>12:00 |
| S139 | 1  | ((de near chuck or " de-chuck") and (plasma near(coat\$4 or deposit)))  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>12:00 |

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|------|------|--|---|----|-----|---------------------|
| S140 | 25   | ((de near chuck or " de-chuck") and (plasma same(coat\$4 or deposit))) | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>13:40 |
| S141 | 6    | "2006004506"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>13:29 |
| S142 | 13   | "931272"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>13:29 |
| S143 | 64   | (de near chuck or " de-chuck") and plasma                              | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:26 |
| S144 | 2    | "20040137169"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:33 |
| S145 | 0    | (( before with (substrate or wafer)) with lift) and palsma             | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:34 |
| S146 | 0    | (( before same (substrate or wafer)) with lift) and palsma             | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:34 |
| S147 | 0    | (( before same (substrate or wafer)) with lift\$4) and palsma          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:34 |
| S148 | 0    | (( before same (substrate or wafer)) same lift\$4) and palsma          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:35 |
| S149 | 2940 | (( before same (substrate or wafer)) same lift\$4)                     | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:35 |

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|------|--------|---|---|----|-----|---------------------|
| S150 | 957    | (( before same (substrate or wafer)) same lift\$4)and plasma  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:35 |
| S151 | 2940   | (( before same (substrate or wafer)) same lift\$4)sameplasma  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:35 |
| S152 | 223    | (( before same (substrate or wafer)) same lift\$4)same plasma | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:35 |
| S153 | 34     | (( before same (substrate or wafer)) same lift\$4)with plasma | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>14:37 |
| S154 | 21     | (( before same (substrate or wafer)) with lift\$4)with plasma | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>15:39 |
| S155 | 2      | "20060011224"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>15:41 |
| S156 | 13     | "682054"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/25<br>15:41 |
| S157 | 21     | "623445"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>18:00 |
| S158 | 5753   | (plasma antenna with coil)with switch                         | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>18:44 |
| S159 | 2137   | (plasma antenna with coil)with switch and coil                | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>18:43 |
| S160 | 205957 | ((("118") or ("156") or ("343"))).CLAS.                       | USPAT; USOCR  | OR | OFF | 2007/10/26<br>18:43 |

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|------|-----|---|---|----|-----|---------------------|
| S161 | 11  | ((plasma and antenna and coil) and switch).<br>clm.   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>18:44 |
| S162 | 2   | "20030003768"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>21:39 |
| S163 | 700 | "4951601"   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>22:43 |
| S164 | 13  | ( plasma near ( deposit or process)) and<br>( lift with ( while or during) with ( wafer or<br>substrate) with plasma)   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>23:00 |
| S165 | 33  | ( plasma near ( deposit or process)) and<br>( (de near chuck)or ( de-chuck) or (de near<br>clamp)with ( before or after) with ( wafer<br>or substrate) with plasma) | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>23:15 |
| S166 | 33  | ( plasma near ( deposit or process)) and<br>( (de near chuck)or ( de-chuck) or (de near<br>clamp)with ( before) with ( wafer or<br>substrate) with plasma)          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>23:15 |
| S167 | 33  | ( plasma near ( deposit or process)) and<br>( (de near chuck)or ( de-chuck) or (de near<br>clamp)with ( wafer or substrate)with<br>( before near\$2 plasma))        | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>23:22 |
| S168 | 9   | ( plasma near ( deposit or process)) and<br>( turn near off) with (RF or voltage or<br>power) with (substarte or wafer)   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/26<br>23:26 |
| S169 | 35  | "478315"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/27<br>00:14 |
| S170 | 75  | ((de near chuck) or ( de near clamp)) and<br>plasma   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/27<br>00:15 |



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|------|-------|--|---|----|-----|---------------------|
| S171 | 75    | ((de near chuck) or ( de near clamp)) and plasma   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/27<br>00:15 |
| S172 | 1     | ((de near chuck) or ( de near clamp)) and (plasma near deposit)                          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/27<br>00:15 |
| S173 | 33    | ((de near chuck) or ( de near clamp)) and (plasma and deposit)                           | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/27<br>00:16 |
| S174 | 57341 | ((de near chuck) or ( de near clamp))with before or after) and (plasma and deposit)      | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/27<br>00:16 |
| S175 | 4     | ((de near chuck) or ( de near clamp))with ( before or after)) and (plasma and deposit)   | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/27<br>00:18 |
| S176 | 0     | ((de near chuck) or ( de near clamp))with ( turn near off)                               | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/27<br>00:43 |
| S177 | 1     | (plasma with deposit) and (( DC near voltage) with bias with (electrostatic near chuck)) | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/27<br>00:47 |
| S178 | 72    | "6316167"  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2007/10/27<br>00:47 |
| S179 | 56    | trouiller.in.  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2008/06/04<br>12:53 |
| S180 | 1     | S179 and plasma  | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2008/06/04<br>12:54 |

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|------|----|--------------------|---|----|----|---------------------|
| S181 | 19 | S179 and resist\$4 | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2008/06/04<br>12:54 |
| S182 | 48 | yorick.in.         | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2008/06/04<br>12:57 |
| S183 | 6  | S179 and S182      | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2008/06/04<br>12:58 |
| S184 | 2  | 10/702049          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2008/06/04<br>13:01 |
| S185 | 2  | 10/847891          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2008/06/04<br>13:03 |
| S186 | 2  | 10/750348          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2008/06/04<br>13:07 |
| S187 | 8  | "6713386"          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2008/06/04<br>13:08 |
| S188 | 81 | "6316167"          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2008/06/04<br>13:54 |
| S189 | 4  | 11/112880          | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2008/06/04<br>15:44 |
| S190 | 2  | "20030216009"      | US-PGPUB;<br>USPAT; USOCR;<br>FPRS; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2008/06/04<br>15:53 |

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